

Post-deposition Catalytic-doping of Microcrystalline Silicon Thin-layer for the Application in Silicon Heterojunction Solar Cell

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Research Center Jülich

Finance

- Budget: 525 Mio. €
- Third Party: ~ 191 Mio. €

Personnel

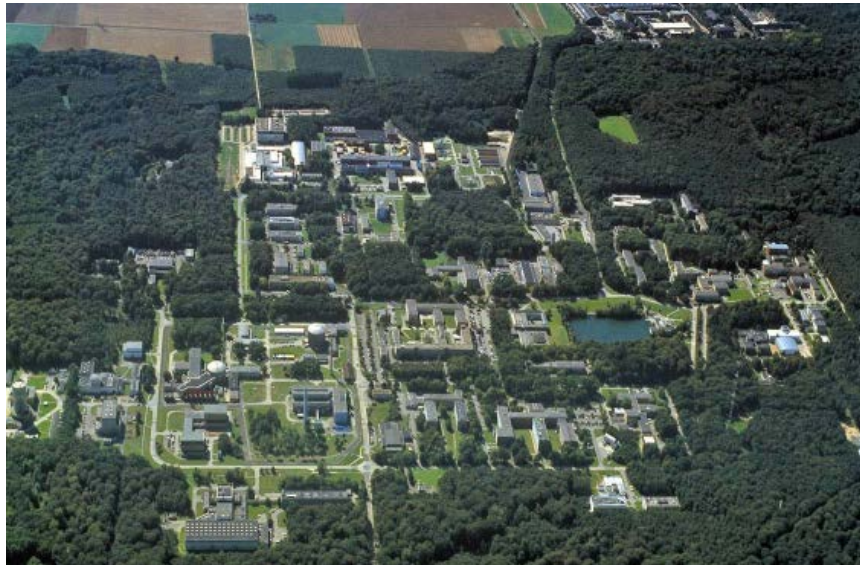
- Staff: 5.800
- scientists: 2.074 (incl. PhDs)
+ 907 guest scientists from
more than 45 countries

Scientific Output

- 8.500 patents
- 192 licenses
- 1.800 articles/year

Research Area

- **Energy and Climate**
- Health
- Information Technology



IEK5-Photovoltaics

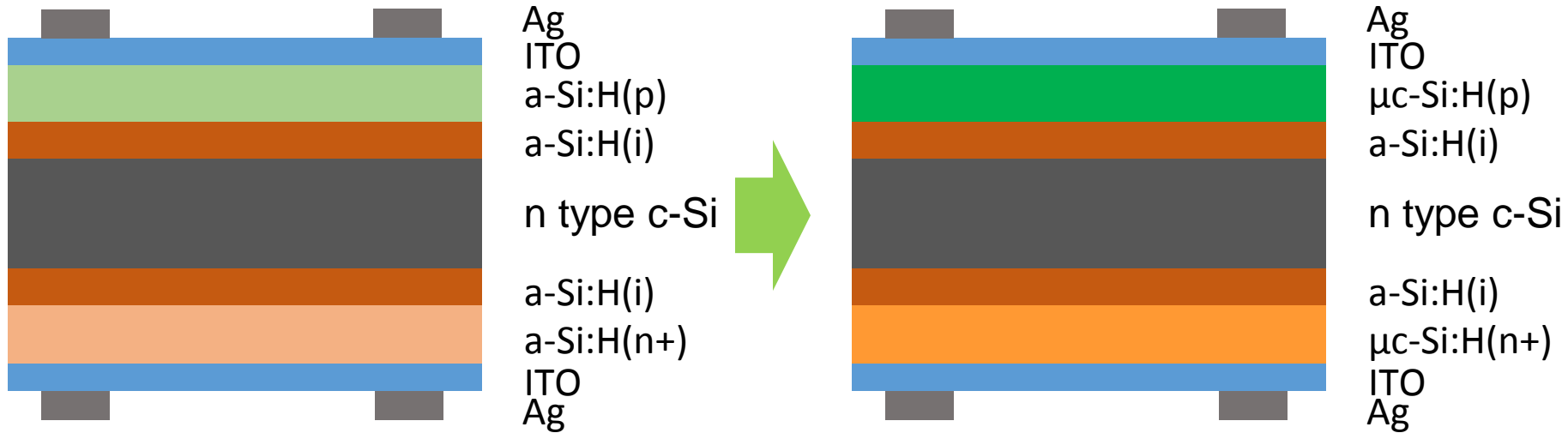
Staff: 120

Scientists: ~25

Students : ~25

- **Thin-film technology for silicon wafer solar cells**
- Si thin-film solar cell application platform
- Novel thin-film materials and concepts
- Thin-film analytics and modeling

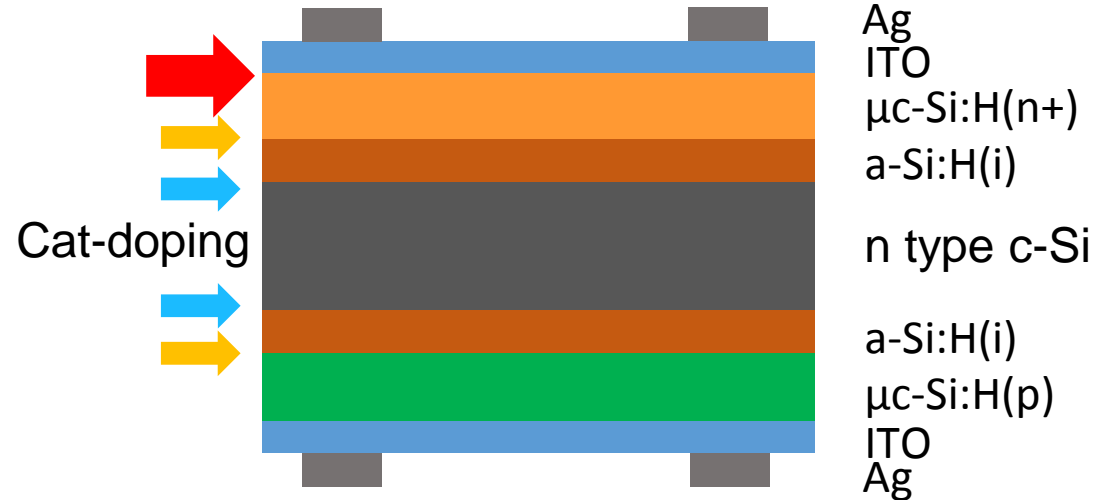
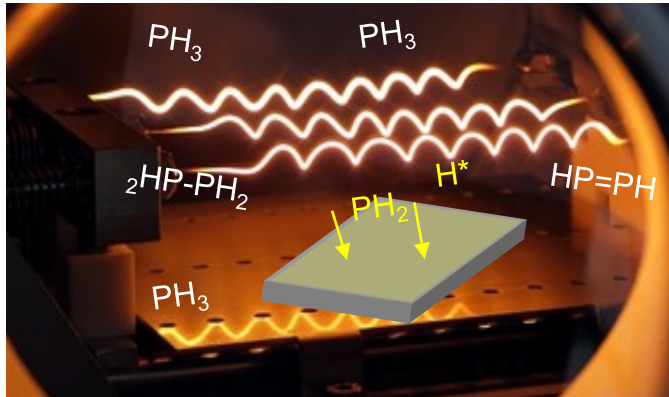




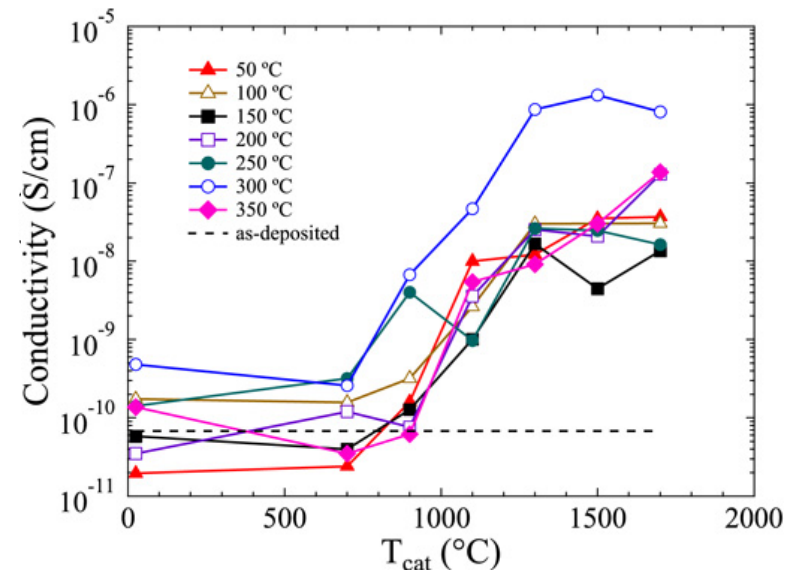
- High V_{OC} due to excellent surface passivation
- Simple, low temperature and up-scalable processes for industrial production
- Compatible with thin wafer process

- $\mu\text{c-Si:H} \rightarrow FF \uparrow$
- rear emitter $\rightarrow J_{SC} \uparrow$
- a-Si:H passivation $\rightarrow V_{OC} \uparrow$
- Efficiency \uparrow

Cat-doping in $\mu\text{c-Si:H}$ SHJ Solar Cell



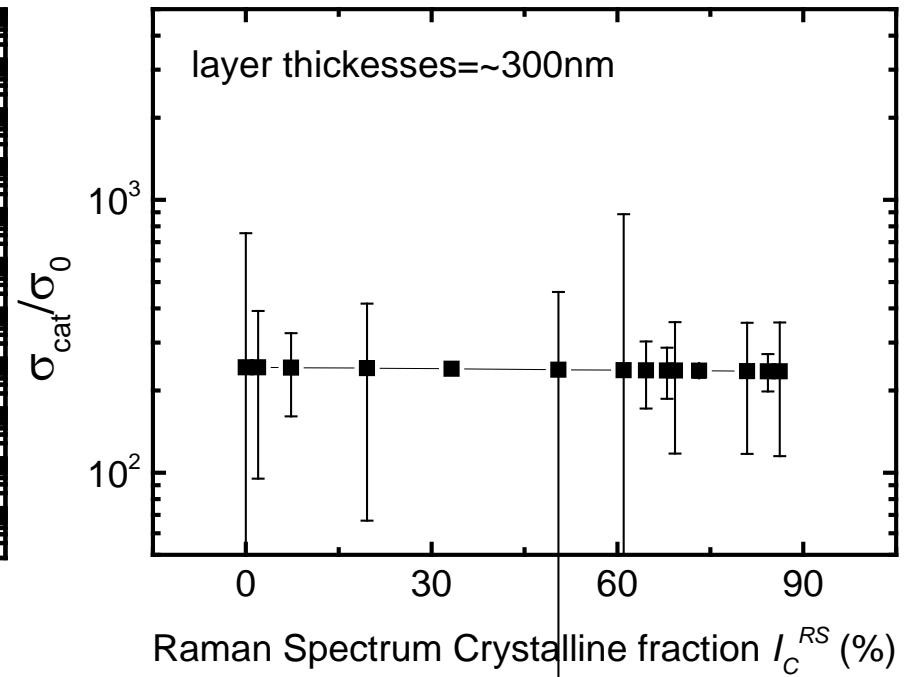
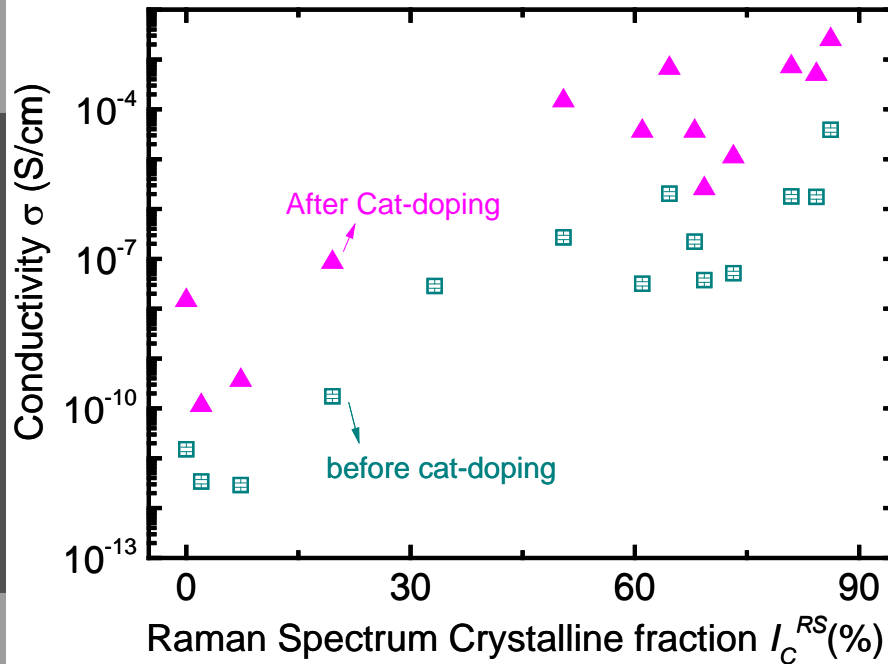
- Low temperature
- Shallow doping depth
- Type conversion
- Improve lifetime by field effect/ H atoms
- Increase conductivity by post-doping
- Compatible with IBC solar cell process



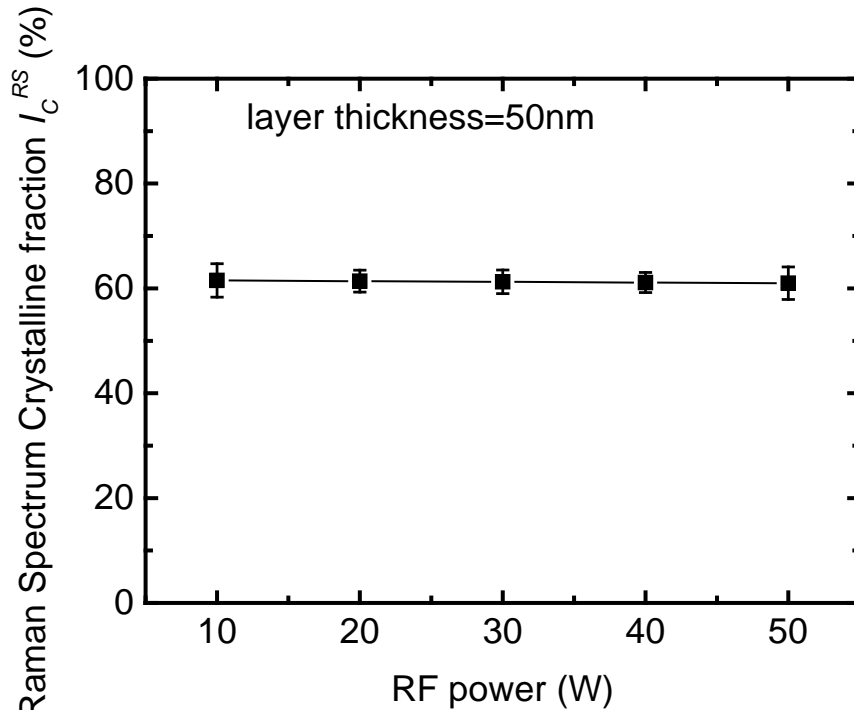
S. Tsuzaki et al., *Jpn. J. Appl. Phys.* 54, 072301 (2015)

J. Seto et al., *Jpn. J. Appl. Phys.* 55, 04ES05 (2016)

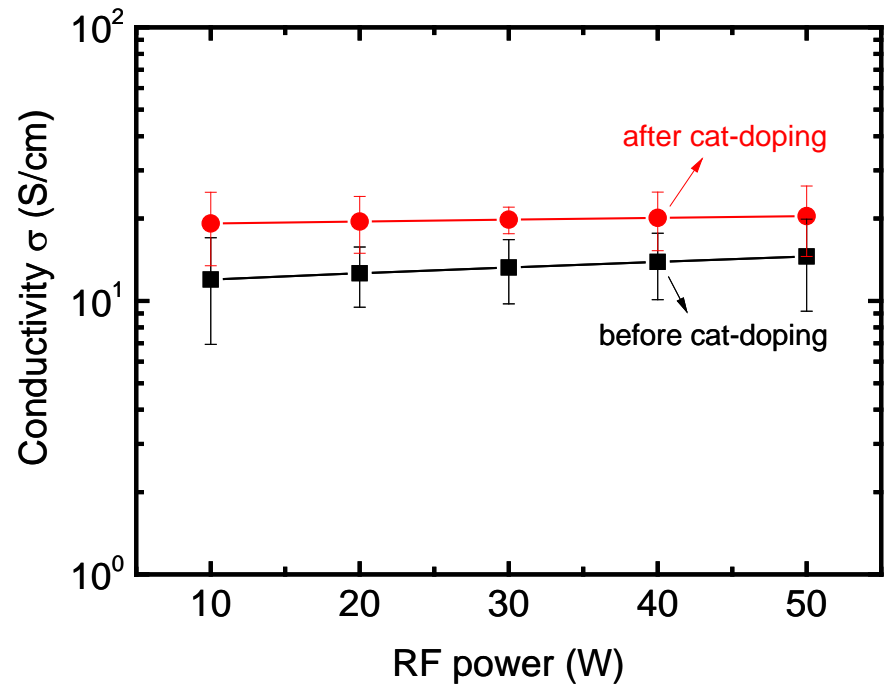
- $T_{\text{wire}} = 1300^\circ\text{C}$, $T_{\text{sub}} = 150^\circ\text{C}$
- $f_{\text{PH}_3} = 20\text{sccm}$, $t = 10\text{min}$
- $\text{Pressure} = 1\text{Pa}$, $\text{Distance} = 90\text{mm}$



- Cat-doping \rightarrow Conductivity \uparrow
- Considering the doping depth, several orders of magnitude's improvement



- $T_{wire} = 1300^\circ\text{C}$, $T_{sub} = 200^\circ\text{C}$
- $f_{PH3} = 20\text{ sccm}$, $t = 10\text{ min}$
- $Pressure = 1\text{ Pa}$, Distance = 90mm

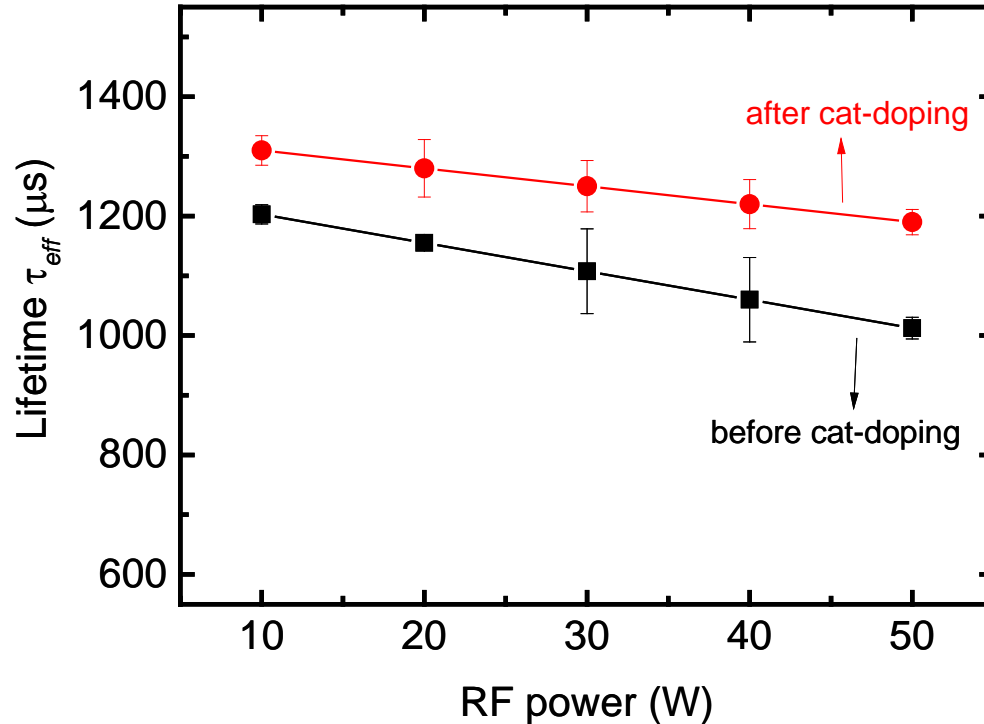


- Crystallinity stayed in a small range though the RF powers changed in a big range

- Conductivity slightly increased after Cat-doping

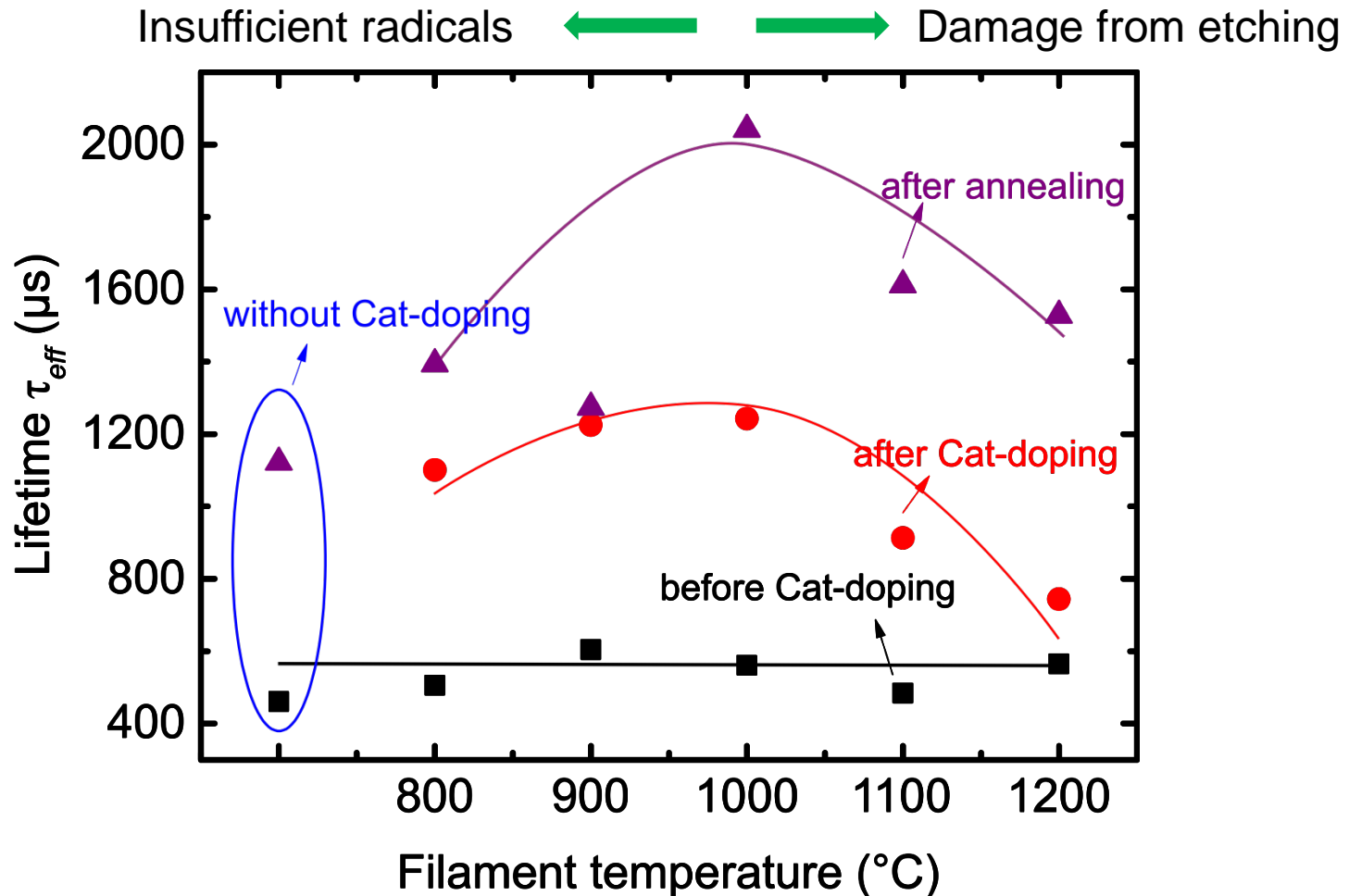
Cat-doping of $\mu\text{c-Si:H(n)}$ on wafers

- $T_{\text{wire}} = 1300^\circ\text{C}$, $T_{\text{sub}} = 200^\circ\text{C}$
- $f_{\text{PH3}} = 20\text{sccm}$, $t = 10\text{min}$
- $\text{Pressure} = 1\text{Pa}$, $\text{Distance} = 90\text{mm}$



- Lifetime decreases with increasing RF power probably due to ion bombardment effect
- Lifetime improved after CAT-doping probably due to the field induced passivation

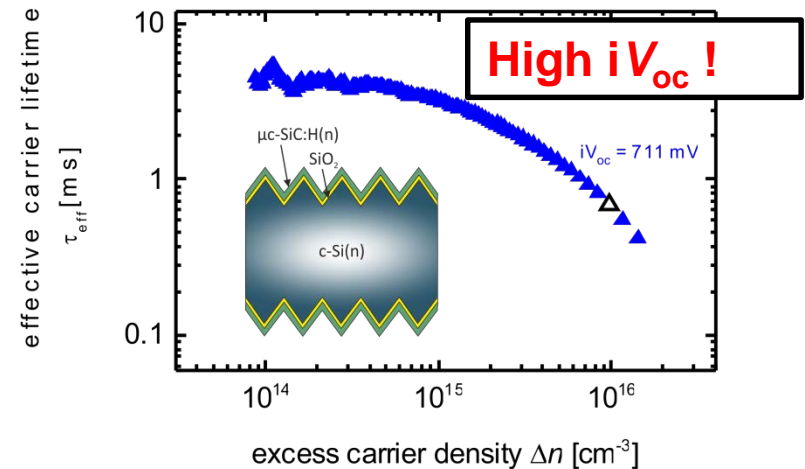
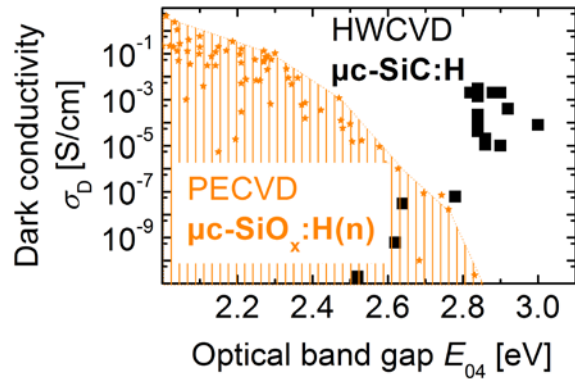
Cat-doping with different T_{wire}



- Cat-doping can improve lifetime by field effect
- After annealing, more P atoms are activated

- $T_{sub} = 200^{\circ}\text{C}$
- $f_{PH3} = 20\text{sccm}, t = 10\text{min}$
- $Pressure = 1\text{Pa}, \text{Distance} = 90\text{mm}$

$\mu\text{c-SiC:H(n)}$ using HWCVD



Main material features:

- High transparency (2.6-3.0 eV)
- High refractive index (2.6-3.0)
- High electrical conductivity (up to 14 S/cm)

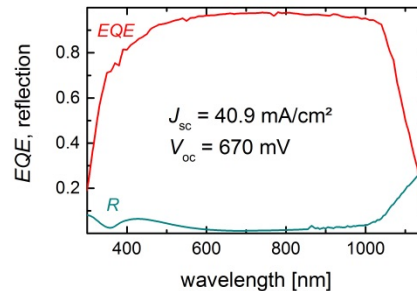
Innovation:

Combine wet-chemical SiO_2 and $\mu\text{c-SiC:H(n)}$ for passivated and transparent front side

Classical SHJ solar cell

$\text{Ag/ITO}/\mu\text{c-SiC:H(n)}/\text{SiO}_2/$
 $\text{c-Si(n)}/$
 $\text{a-Si:H(i)}/\mu\text{c-SiO}_x\text{:H(p)}/\text{ITO}/$

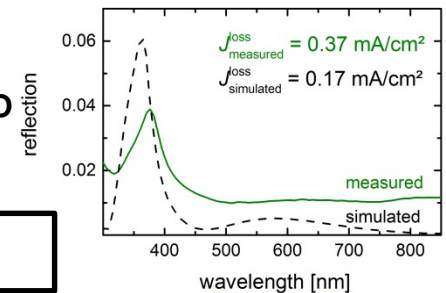
High J_{sc} !



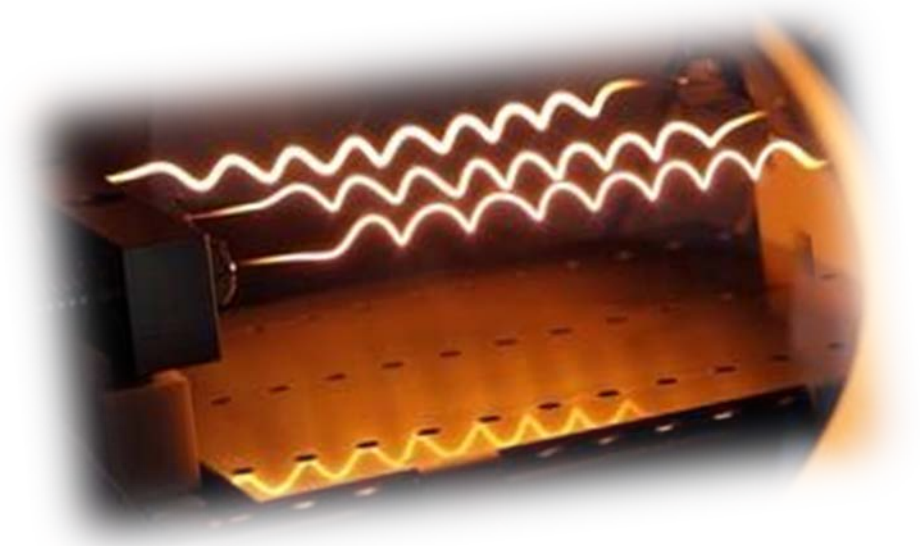
IBC - SHJ solar cell

$\text{MgF}_2/\text{SiN}_x/\mu\text{c-SiC:H(n)}/\text{SiO}_2/$
 $\text{c-Si(n)}/$
 $\text{a-Si:H(i)}/\text{IBC}$

Low reflection !



- Cat-doping can dope both intrinsic and n-type $\mu\text{c-Si:H}$
- Cat-doping can improve the τ_{eff} of SHJ solar cell with $\mu\text{c-Si:H}$ and give the highest τ_{eff} at $900^{\circ}\text{C}\sim 1000^{\circ}\text{C}$
- Annealing can activate the P atoms which leads to further improvement
- P type Cat-doping of $\mu\text{c-Si:H}$
- Performance of cell with Cat-doping
- IBC-SHJ solar cell using Cat-doping



Thanks

The Silicon Heterojunction Group:

Scientific Staff: K. Ding, A. Lambertz, D.Y. Kim, F. Lentz, L. Ding, W. Duan, O. Astakhov

Technical Staff: U. Gerhards, S. Lynen, M. Meyer

PhD Students: M. Pomaska, A. Richter, S. Nadi, Y. Liu, M. Köhler, H.M. Li

JAIST: Prof. Matsumura: discussion and suggestions

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Thank you for your attention!

